- 10.57 Repeat Problem 10.56 for the case when the electrons are traveling at a saturation velocity of $v_{\text{sat}} = 4 \times 10^6 \text{ cm/s}$.
- **10.56** An n-channel MOSFET has the following parameters:

$$\mu_n = 400 \text{ cm}^2/\text{V-s}$$
 $t_{ox} = 500 \text{ Å}$
 $L = 2 \mu\text{m}$ $W = 20 \mu\text{m}$
 $V_T = +0.75 \text{ V}$

Assume the transistor is biased in the saturation region at $V_{GS} = 4$ V. (a) Calculate the ideal cutoff frequency. (b) Assume that the gate oxide overlaps both the source and drain contacts by 0.75 μ m. If a load resistance of $R_L = 10$ k Ω is connected to the output, calculate the cutoff frequency.

 \triangleright For part a), find the transit time frequency limit as well. For part b) change the overlap to 0.5 μ m.

From Table B.4 and Table B.6, silicon has $n_i = 1.5 \times 10^{10}$ cm⁻³, $\varepsilon_{s,Si} = 11.7\varepsilon_0$, and $\varepsilon_{s,SiO2} = 3.9\varepsilon_0$ at 300 K.

a) From section 10.4.2 of the text, the channel transit time is

$$\tau_t = L/v_{\text{sat}} = 2 \times 10^{-6} \text{ m/} 4 \times 10^4 \text{ m/s} \implies \tau_t = 5 \times 10^{-11} \text{ s} = 50 \text{ ps}.$$

This leads to transit time cutoff frequency of

$$f_{\text{limit}} \cong 1/\tau_t = 1/50 \times 10^{-12}$$
 $\Rightarrow \underline{f_{\text{limit}}} = 20 \text{ GHz}.$

Per (10.96), the ideal cutoff frequency is-

$$f_{T,\text{ideal}} = \frac{\mu_n (V_{GS} - V_T)}{2\pi L^2} = \frac{400 (10^{-4}) (4 - 0.75)}{2\pi (2 \cdot 10^{-6})^2}$$

$$\Rightarrow \underline{f_{T,\text{ideal}} = 5.1725 \times 10^9 \text{ Hz} = 5.17 \text{ GHz}}.$$

b) Using (10.35), the oxide capacitance per unit area is

$$C_{ox} = \varepsilon_{ox} / t_{ox} = 3.9(8.8541878 \times 10^{-12} \text{ F/m}) / 500 \times 10^{-10} \text{ m}$$

 $\Rightarrow C_{ox} = 6.9062665 \times 10^{-4} \text{ F/m}^2 = 6.9062665 \times 10^{-8} \text{ F/cm}^2.$

The gate-drain & gate-source overlap areas are

$$A_{\text{overlap}} = \text{overlap}(W) = 0.5 \times 10^{-6} (20 \times 10^{-6}) \implies A_{\text{overlap}} = 1 \times 10^{-11} \text{ m}^2.$$

The gate-drain & gate-source parasitic capacitances are-

$$C_{gdp} = C_{gsp} = C_{ox} (A_{\text{overlap}}) = 6.9062665 \times 10^{-4} (10^{-11})$$

 $\Rightarrow C_{gdp} = C_{gsp} = 6.9062665 \times 10^{-15} \text{ F.}$

Per p. 427 of text, with the MOSFET in saturation, $C_{gd} \rightarrow 0$ and

$$C_{gs} = C_{ox} WL = 6.9062665 \times 10^{-4} (20 \times 10^{-6}) 2 \times 10^{-6} \Rightarrow C_{gs} = 2.76251 \times 10^{-14} \text{ F}.$$

Now, the total gate-drain & gate-source capacitances are

$$C_{gdT} = C_{gd} + C_{gdp} = 0 + 6.9062665 \times 10^{-15}$$
 $\Rightarrow C_{gdT} = 6.9062665 \times 10^{-15} \,\mathrm{F}$, and $C_{gsT} = C_{gs} + C_{gsp} = 2.76251 \times 10^{-14} + 6.9062665 \times 10^{-15}$ $\Rightarrow C_{gsT} = 3.45313 \times 10^{-14} \,\mathrm{F}$.

To find the Miller capacitance C_M , we will need the transconductance g_m of the MOSFET. In saturation, the transconductance is (10.77)

$$g_{ms} = \frac{W \mu_n C_{ox}}{L} (V_{GS} - V_T) = \frac{20 \cdot 10^{-6} \left(400 \cdot 10^{-4}\right) 6.9062665 \cdot 10^{-4}}{2 \cdot 10^{-6}} (4 - 0.75)$$

$$\Rightarrow g_{ms} = 8.978146 \times 10^{-4} \text{ S}.$$

Per (10.91), the Miller capacitance is

$$C_M = C_{gdT}(1 + g_{ms} R_L) = 6.9062665 \times 10^{-15} [1 + (8.978146 \times 10^{-4}) 10 \times 10^3]$$

 $\Rightarrow C_M = 6.89117 \times 10^{-14} \text{ F}.$

Per (10.95), the cutoff frequency is

$$f_T = \frac{g_{ms}}{2\pi (C_{gsT} + C_M)} = \frac{8.978146 \cdot 10^{-4}}{2\pi (3.45313 \cdot 10^{-14} + 6.89117 \cdot 10^{-14})}$$

$$\Rightarrow \underline{f_T = 1.38136} \times \underline{10^9 \text{ Hz} = 1.38 \text{ GHz}}.$$